

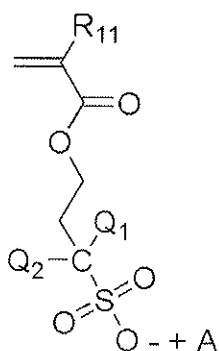
COMPOUND, POLYMER COMPRISING THE COMPOUND, AND CHEMICALLY
AMPLIFIED RESIST COMPOSITION COMPRISING THE POLYMER

ABSTRACT

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Provided are a compound, a polymer containing this compound, and a chemically amplified resist composition including the polymer, and a compound represented by the following formula (1) and a polymer containing the compound as a monomer are provided.

[Formula 1]



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wherein in the formula (1), the definitions of R₁₁, Q₁, Q₂ and A⁺ are as described in the specification. When the compound and a polymer containing this compound as a monomer are used in a chemically amplified resist composition, the resist composition may have excellent sensitivity and higher stability with a reduced amount of gas discharge, and may have higher resolution and lower line-edge-roughness.

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